

## Electronic Patent Application Fee Transmittal

Application Number:	10522036
Filing Date:	19-Jan-2005
Title of Invention:	Chemically amplified positive photo resist composition and method for forming resist pattern
First Named Inventor/Applicant Name:	Kenji Maruyama
Filer:	Neil S. Bartfeld/L. Racquel Raymond
Attorney Docket Number:	SHIGA7.004APC

Filed as Large Entity

### **U.S. National Stage under 35 USC 371 Filing Fees**

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
<b>Post-Allowance-and-Post-Issuance:</b>				
<b>Extension-of-Time:</b>				
Extension - 2 months with \$120 paid	1252	1	330	330

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Miscellaneous:</b>				
<b>Total in USD (\$)</b>				<b>330</b>